Electronic Acknowledgement Receipt					
EFS ID:	1097751				
Application Number:	10827539				
Confirmation Number:	3430				
Title of Invention:	Surface treatment for metal-polymer laminated electrochemical cell package				
First Named Inventor:	Edward Earl Welker				
Correspondence Address:	JIMMY L. FUNKE DELPHI TECHNOLOGIES, INC. Legal Staff, Mail Code: 480-410-202 P.O. Box 5052 Troy MI 48007-5052 US 2488131214				
Filer:	James R. Yee/Melissa Dadisman				
Filer Authorized By:	James R. Yee				
Attorney Docket Number:	DP-310354				
Receipt Date:	29-JUN-2006				
Filing Date:	19-APR-2004				
Time Stamp:	15:54:55				
Application Type:	Utility				
International Application Number:					

Payment information:

Submitted with Payment	no	
------------------------	----	--

File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part	Pages			
1	Assignee showing of ownership per 37 CFR 3.73(b).	10827539.pdf	60357	no	1			
Warnings:								
Information:								
	Total Files Size (in bytes): 60357							

This Acknowledgement Receipt evidences receipt on the noted date by the USPTO of the indicated documents, characterized by the applicant, and including page counts, where applicable. It serves as evidence of receipt similar to a Post Card, as described in MPEP 503.

New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.